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(12) **United States Design Patent** (10) **Patent No.:** **US D768,927 S**  
**Eisenberg** (45) **Date of Patent:** **\*\* Oct. 11, 2016**

(54) **FACIAL MASK**

FOREIGN PATENT DOCUMENTS

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OTHER PUBLICATIONS

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(52) **U.S. Cl.**  
USPC ..... **D28/9**

(58) **Field of Classification Search**  
USPC ..... D2/741, 865, 999; D21/660, 683;  
D29/108-111; D28/9  
CPC ..... A61F 9/26; A61F 9/04; A61F 9/06;  
A61F 9/045; A41D 13/11; A41D 13/1107;  
A41D 13/1161; A41D 13/1169; A41D  
13/1192; A41D 13/1184; A63B 71/10;  
A63H 3/365  
See application file for complete search history.

‘Sexylook’, Apr. 13, 2011, found on the Internet at: <http://bijinblair.blogspot.com/2011/04/sexylook-firming-moisture-ultra.html>, downloaded on Feb. 17, 2016.\*  
“CTW Girl”, cover page and page showing inside page showing advertisement of almost identical mask design, shown in lace, published Sep. 2013, published by China Times Weekly, LTD, Taipei, Taiwan.†  
“Mina” magazine, cover page and inside page showing advertisement of mask, published Dec. 2013 by Ching-Win Publishing Co. LTD. of Taipei, Taiwan.†  
“CTW Girl” magazine, cover page and inside page showing advertisement for mask, Oct. 2013, published by China Times Weekly, LTD of Taipei, Taiwan.†  
Timeless Truth Australia, Facebook page of “Timeline Truth Australia” showing facial mask, May 17, 2013, published online by Facebook.†  
Author: “BuukaaBaby”, series of Youtube screenshots featuring a facial mask, published on Dec. 1, 2011, on Youtube.com.†

\* cited by examiner  
† cited by third party

(56) **References Cited**

U.S. PATENT DOCUMENTS

1,810,486	A *	6/1931	Lancaster	602/74
3,878,563	A *	4/1975	Pulju	2/9
4,095,290	A *	6/1978	O’Brien	2/9
5,706,828	A *	1/1998	Shiota	128/857
D564,705	S *	3/2008	Ohnishi et al.	D28/9
D570,541	S *	6/2008	Ohnishi et al.	D28/9
D601,210	S *	9/2009	Woye et al.	D21/660
D608,500	S *	1/2010	Lu et al.	D28/9
D634,473	S *	3/2011	Koike	D28/9
D638,164	S *	5/2011	Tajima	D28/9
8,540,445	B2 *	9/2013	Omoto	401/6
2006/0048278	A1 *	3/2006	Pitsolis	2/206
2009/0241242	A1 *	10/2009	Beatty et al.	2/206
2010/0191314	A1 *	7/2010	Young	607/109
2014/0298826	A1 *	10/2014	Guor	62/4
2014/0318565	A1 *	10/2014	Ito et al.	132/200
2014/0352031	A1 *	12/2014	Choi et al.	2/173

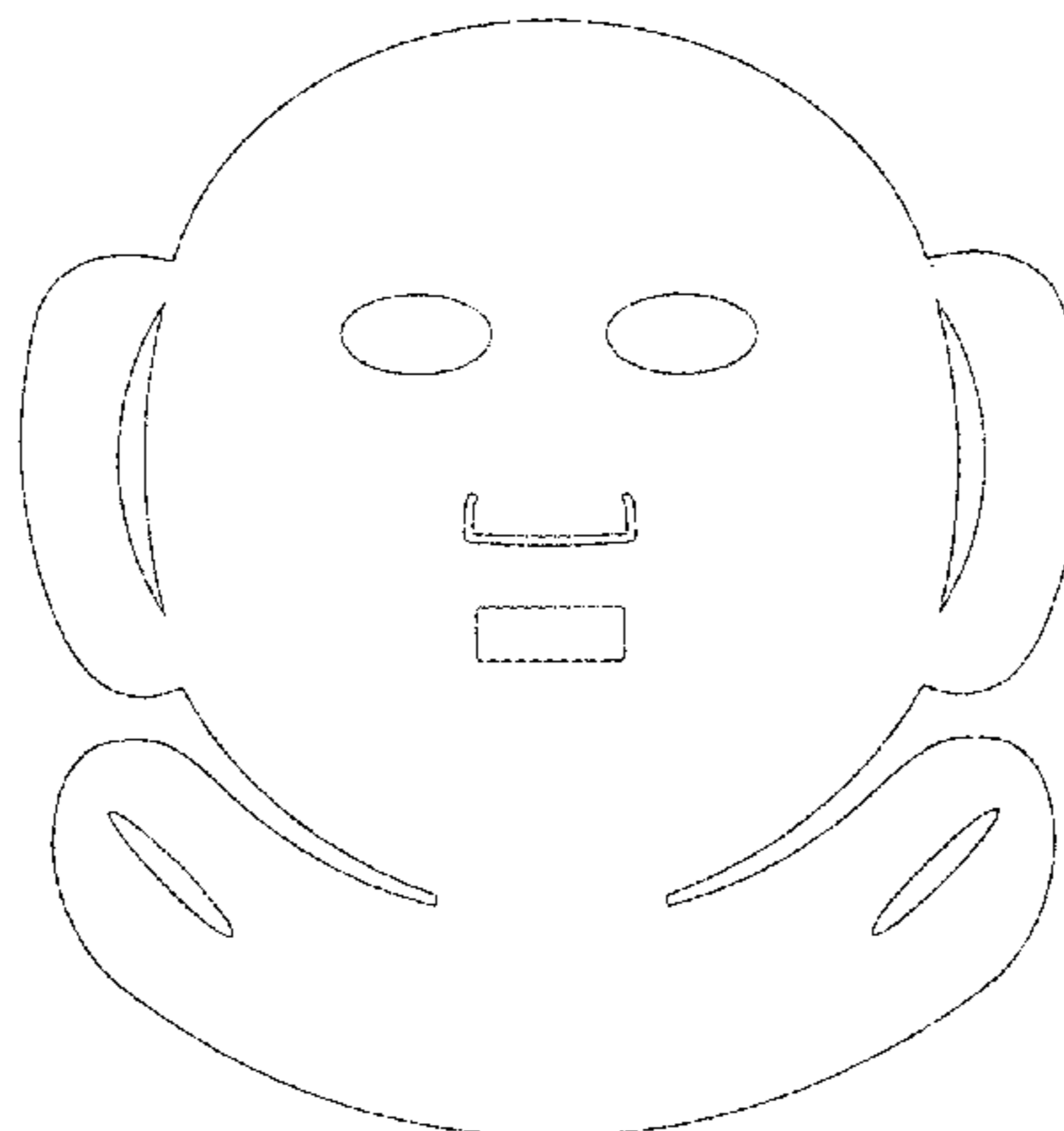
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(57) **CLAIM**  
The ornamental design for a facial mask, as shown.

**DESCRIPTION**

FIG. 1 is a perspective view showing my new design.  
FIG. 2 is a front view thereof; and,  
FIG. 3 is a rear view thereof.

**1 Claim, 3 Drawing Sheets**



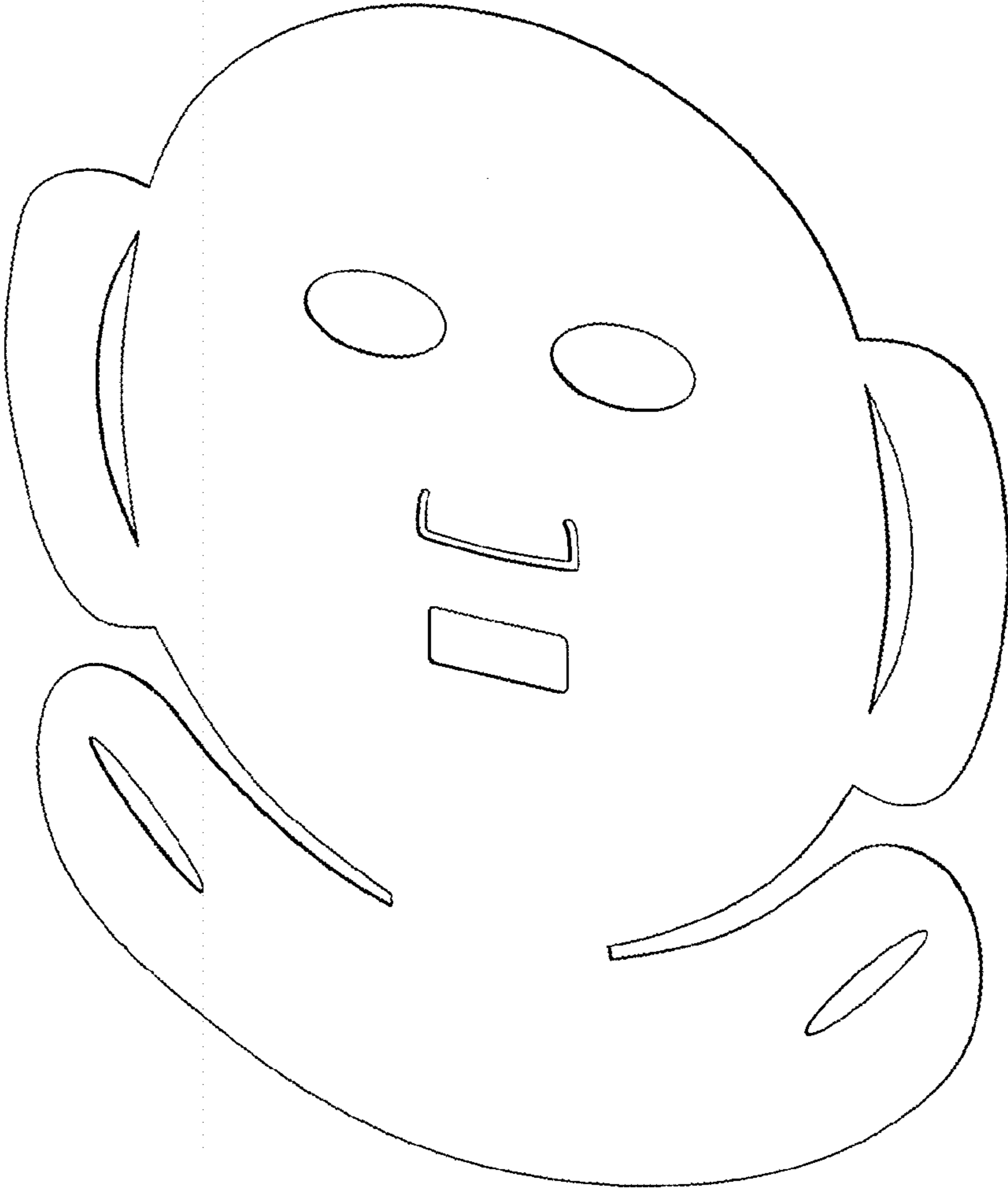


FIG.1

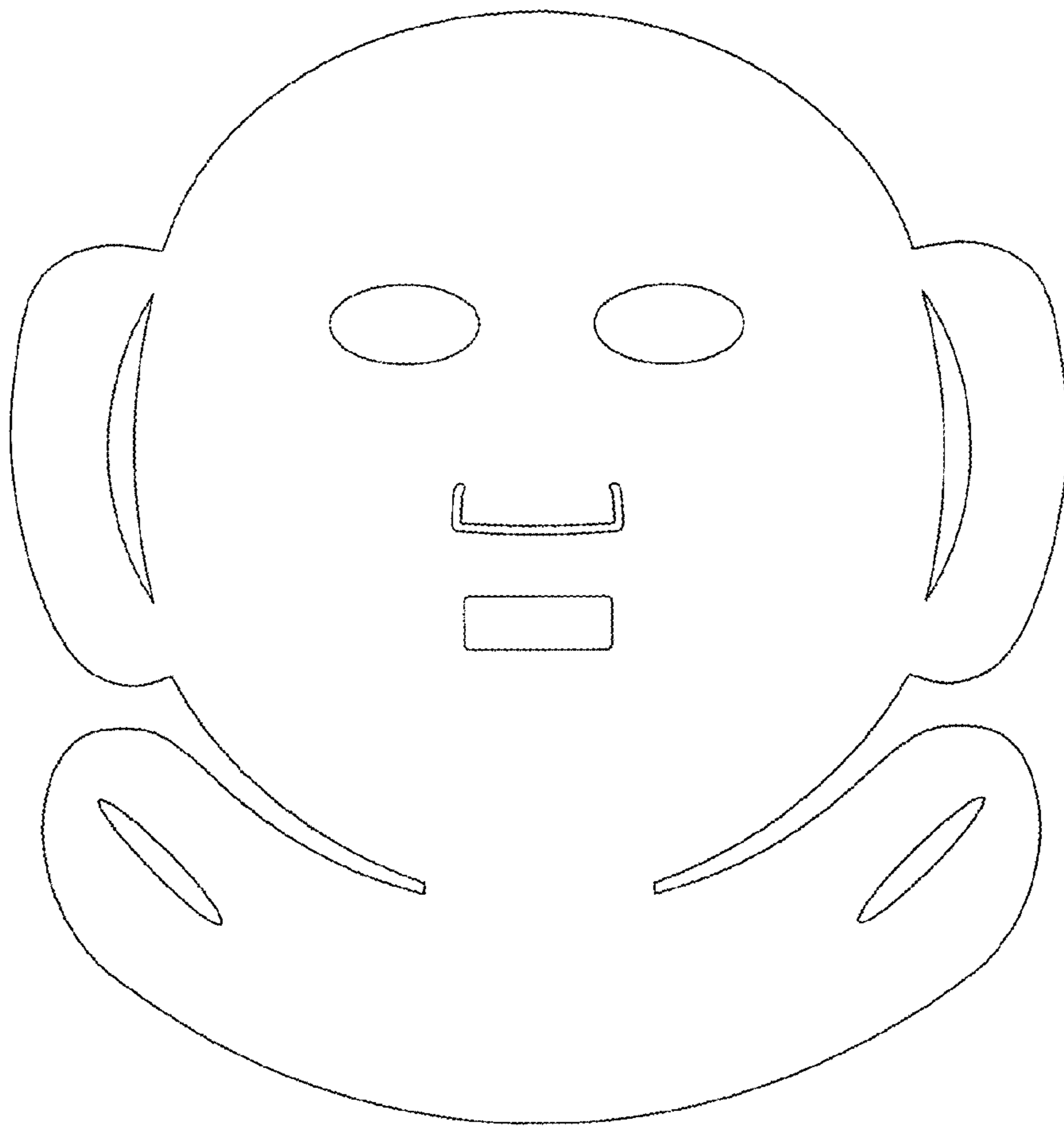


FIG.2

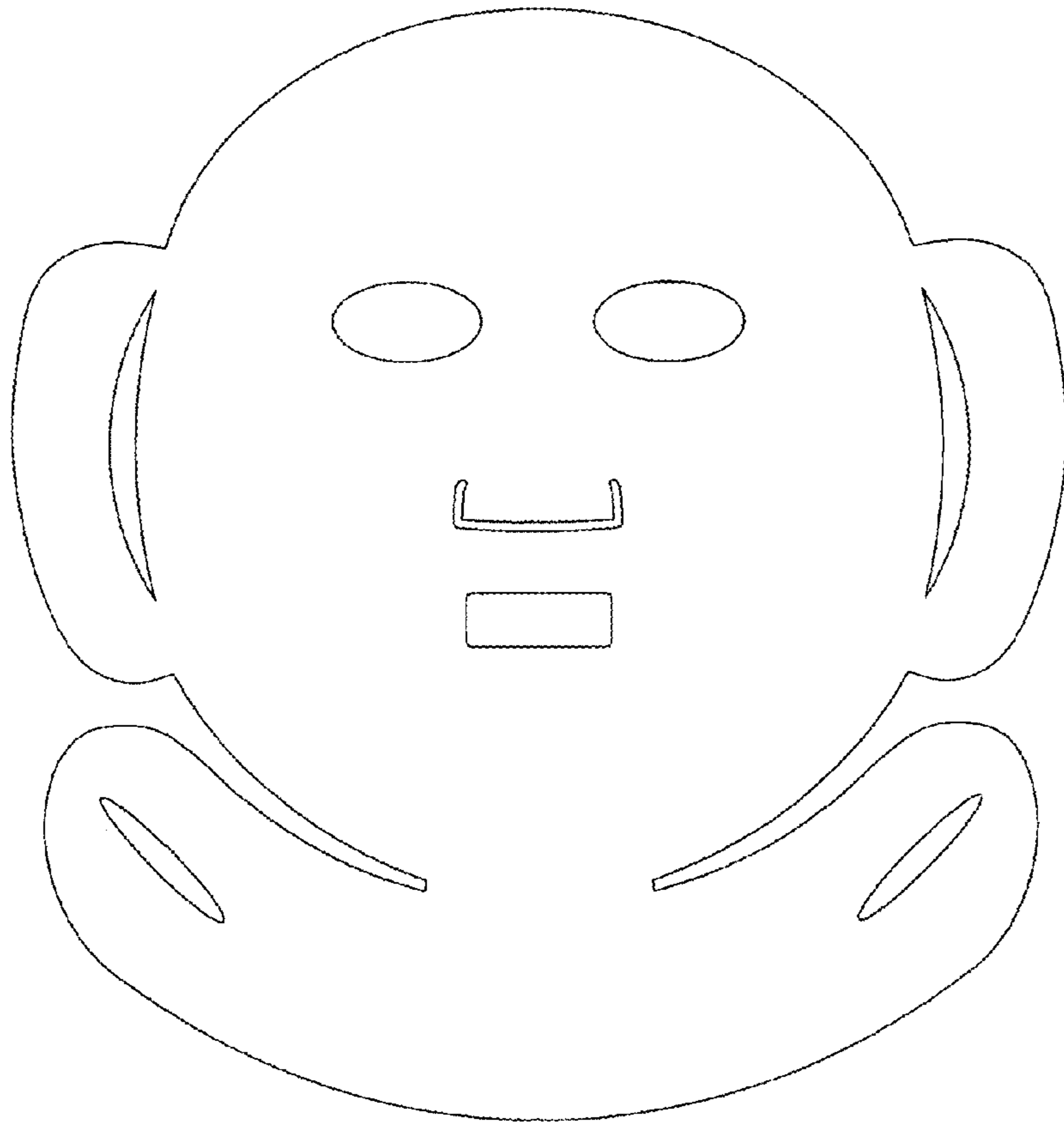


FIG.3